

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property
Organization
International Bureau



(43) International Publication Date
20 January 2005 (20.01.2005)

PCT

(10) International Publication Number
WO 2005/006360 A2

(51) International Patent Classification⁷:

H01G

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(21) International Application Number:

PCT/JP2004/010163

(22) International Filing Date: 9 July 2004 (09.07.2004)

(25) Filing Language:

English

(26) Publication Language:

English

(30) Priority Data:

2003-194846	10 July 2003 (10.07.2003)	JP
60/487,593	17 July 2003 (17.07.2003)	US
2004-023120	30 January 2004 (30.01.2004)	JP
60/542,854	10 February 2004 (10.02.2004)	US

(81) Designated States (*unless otherwise indicated, for every kind of national protection available*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(84) Designated States (*unless otherwise indicated, for every kind of regional protection available*): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

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Published:

— *without international search report and to be republished upon receipt of that report*

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: JIG FOR PRODUCING CAPACITOR, PRODUCTION METHOD FOR CAPACITOR AND CAPACITOR

(57) Abstract: The present invention provides a capacitor production method where an electric conductor having a dielectric layer formed thereon is used as one electrode and a semiconductor layer is formed by energization to be the other electrode, comprising the energization performed through a constant current diode, and also provides a jig for producing capacitors, which is used for forming semiconductor layers by energization on two or more electric conductors each having formed on the surface thereof a dielectric layer, the jig comprising two or more current ejection-type constant current sources in accordance with the number of electric conductors, which current sources each has an output electrically connected in series with a connection terminal for the electric conductor. Use of the jig of the present invention, enables production of capacitors including semiconductor as one electrode with a small variation in the capacitance.



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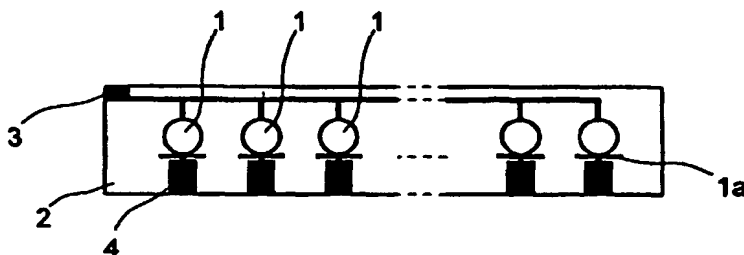
(43) International Publication Date
20 January 2005 (20.01.2005)

PCT

(10) International Publication Number
WO 2005/006360 A3

- (51) International Patent Classification⁷: **H01G 13/00**, 9/15, 9/04
- (21) International Application Number: PCT/JP2004/010163
- (22) International Filing Date: 9 July 2004 (09.07.2004)
- (25) Filing Language: English
- (26) Publication Language: English
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- Published:
— with international search report
- (88) Date of publication of the international search report:
31 March 2005
- For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

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